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PATENT
Customer No. 22,852
Attorney Docket No. 04329.2072-01



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
)
Katsuki OHASHI et al.) Group Art Unit: 1756
)
Serial No.: 09/870,702) Examiner: Unknown
)
Filed: June 1, 2001.)
)
For: METHOD FOR REPAIRING A)
PHOTOMASK, METHOD FOR)
INSPECTING A PHOTOMASK,)
METHOD FOR MANUFACTURING)
A PHOTOMASK, AND METHOD)
FOR MANUFACTURING A)
SEMICONDUCTOR DEVICE)

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Assistant Commissioner for Patents
Washington, DC 20231

Sir:

PRELIMINARY AMENDMENT

Prior to the examination of the above application, please amend this application
as follows:

IN THE SPECIFICATION:

Page 38, replace the paragraph beginning on line 16, with the following new
paragraph:

Point-type sensors, such as a photodiode (PD) and a photomultiplier (PMT), may
be employed. When sensors of this type are used, the inspection optical system may
be the same as that used when the TDI sensor is used. The point-type sensors are
non-accumulation type sensors, and when they are used, signals representing

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LAW OFFICES
FINNEGAN, HENDERSON,
FARABOW, GARRETT
& DUNNER, L.L.P.
1300 I STREET, N.W.
WASHINGTON, DC 20005
202-408-4000